

Cu Alloy Wire

Introduction

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Contents

- **Benefit of Cu alloy wire**
- **Excellent characteristic of Cu alloy**
 - > **2nd Bondability**
 - > **1st Bondability**
 - > **Reliability**
- **Summary of Cu alloy bonding wire**

Benefit of Cu alloy wire

◆For customer using **bare Cu** wire

1. Better 2nd Bondability

- Wider 2nd bond process window.
- Higher stitch pull strength.

2. Higher reliability

- Longer HTS life.

◆For customer using **Pd coated Cu** wire

1. Cost

- Lower cost

2. 1st Bondability

- Less Al splash

Excellent characteristic of Cu alloy

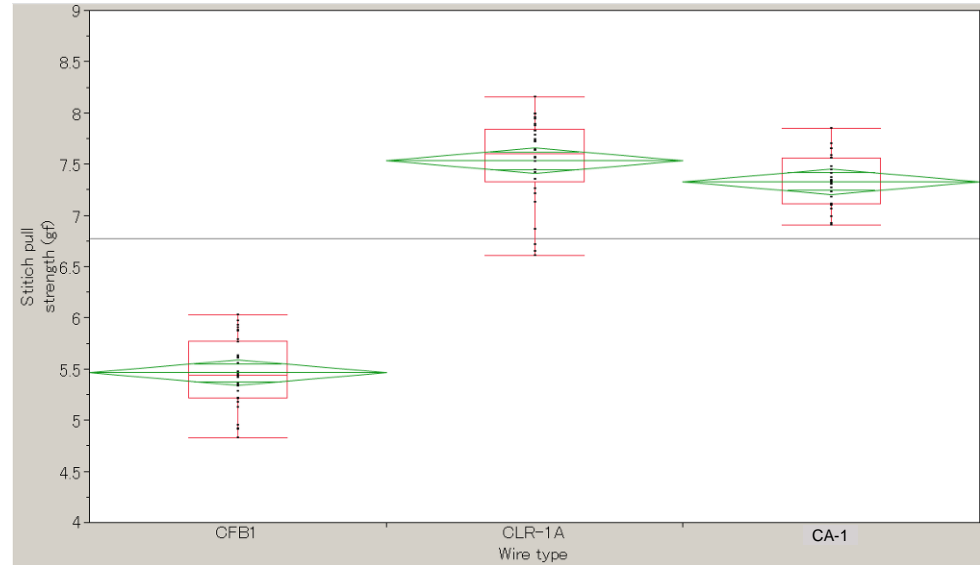
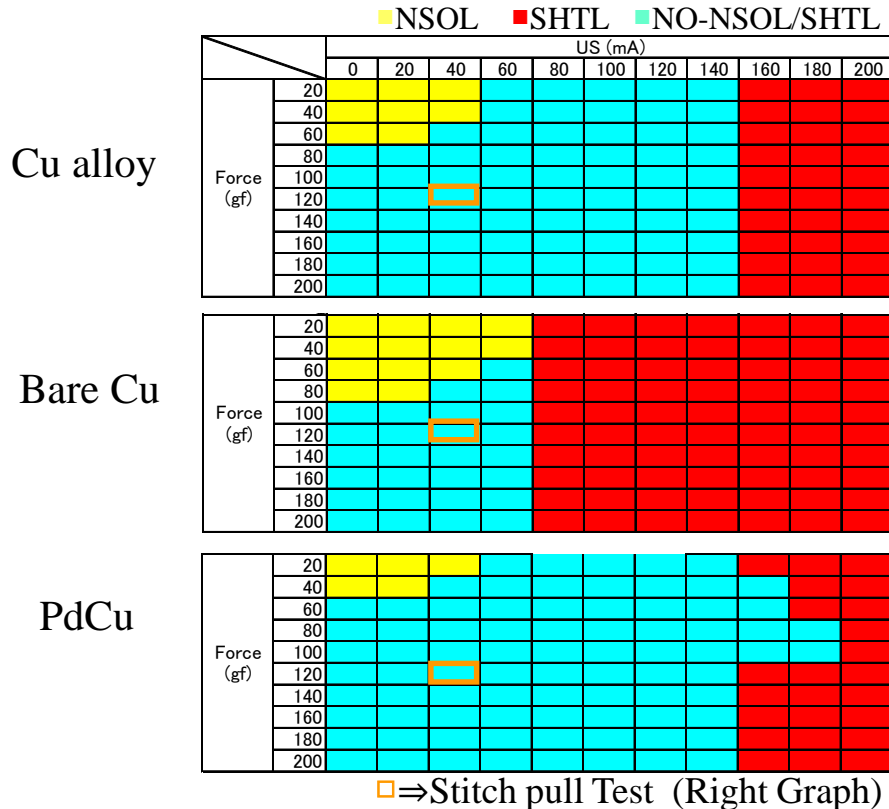
【2nd Bondability】

◆ Bonding parameter window

Wire : φ20um, N=200

◆ Stitch pull strength

(Force 120gf, US 40mA)



Wire : φ20um, N=200

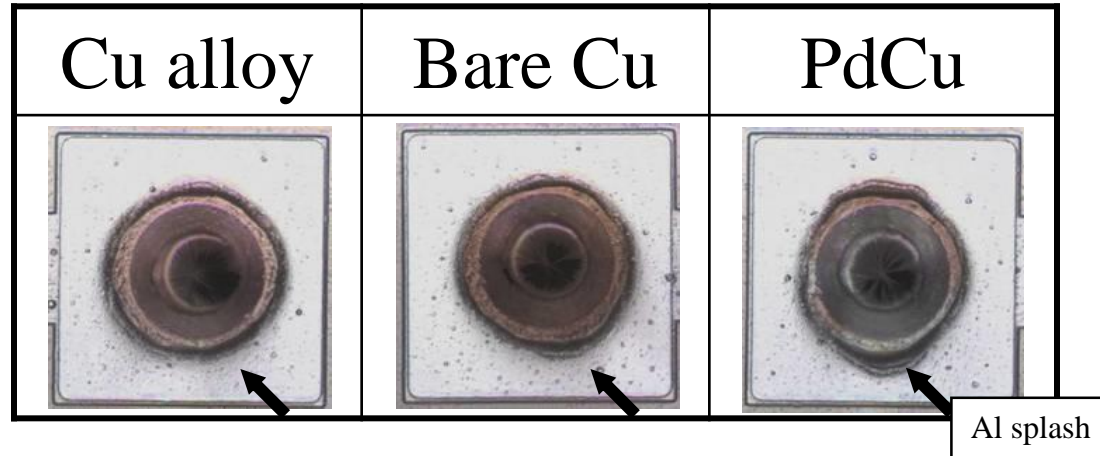
Bonder: KnS Maxum Plus (Cu kit)
 Capillary : SPT SU-25080-385F-ZU34TP
 Sub: Dummy substrate ,Ag electro plating
 Bonding Temp: 220°C

2nd Bonding window of Cu alloy is wider than bare Cu (Almost same as PdCu)

Excellent characteristic of Cu alloy

【1st Bondability】

Wire : $\phi 20\mu\text{m}$, FAB : $\phi 38\mu\text{m}$

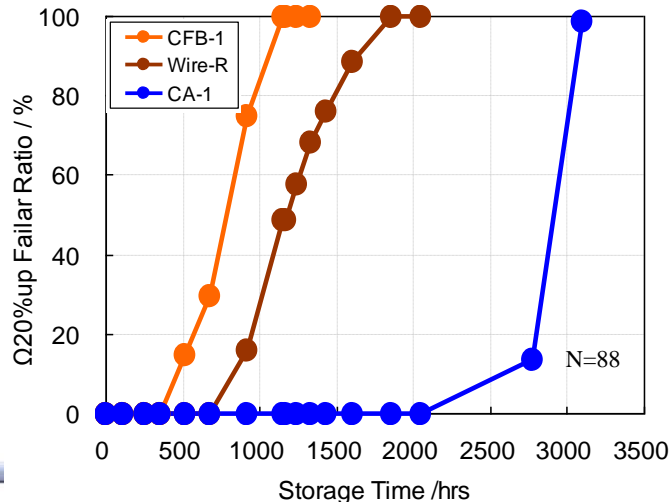


The state of Al splash of Cu alloy is almost same as bare Cu.

【Reliability】

HTS 175°C, QFP, Non-Green resin

◆ Failure Ratio



Cu alloy shows excellent reliability.

Details of Technical Data

➤ Evaluation wire

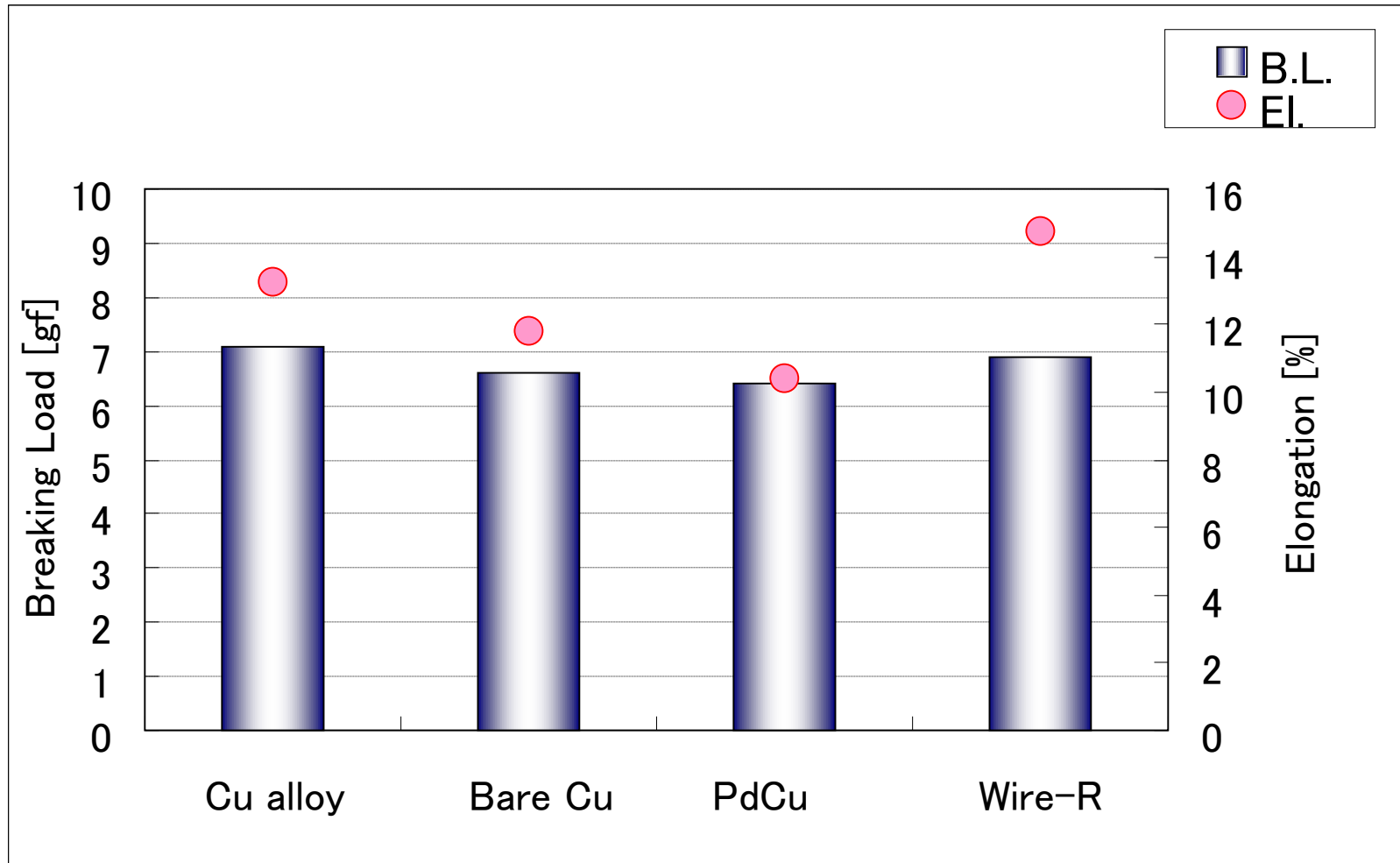
Type : Cu alloy, 4N bare Cu, PdCu, Wire-R (Competitor Cu-Alloy)

Wire Diameter : ϕ 20um

➤ Evaluation Data

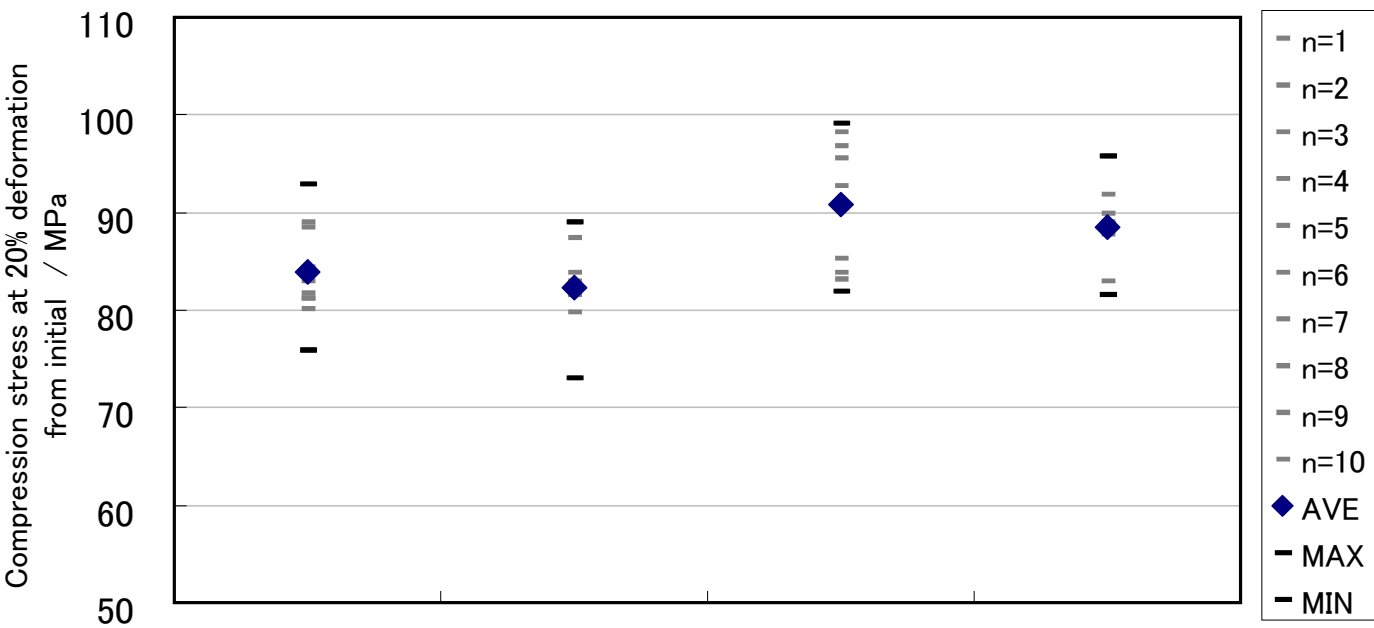
- 1. Mechanical properties (BL, El)**
- 2. Compression test of FAB**
- 3. Resistivity**
- 4. FAB Formation**
- 5. 1st Bondability**
- 6. 2nd Bondability**
- 7. Reliability**
- 8. Summary (Details of Technical Data)**

Mechanical Property Wire Comparisons (BL,El)



Breaking load and elongation of Cu alloy is higher than bare Cu and PdCu

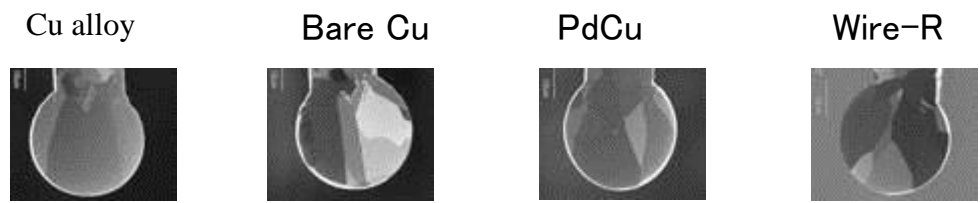
Compression test of FAB



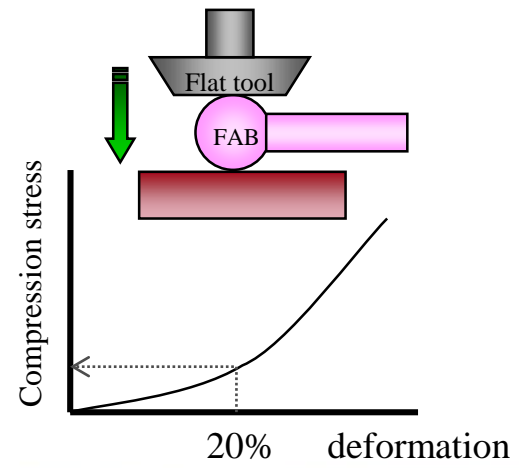
【FAB Making condition】
 Wire : φ20um
 FAB : 38um(Target)
 Bonder : K&S Iconn
 Gas : N₂-5%H₂, 0.5l/min
 Loop mode : Free Air Ball mode
 EFO Time : 160us
 EFO Current : 70mA

【Measurement Equipment】
 Compression Tester : MCT-7500 (SHIMADZU)

【Measurement Conditions】
 Compression speed : 100mN/sec
 Maximum Load : 1000mN



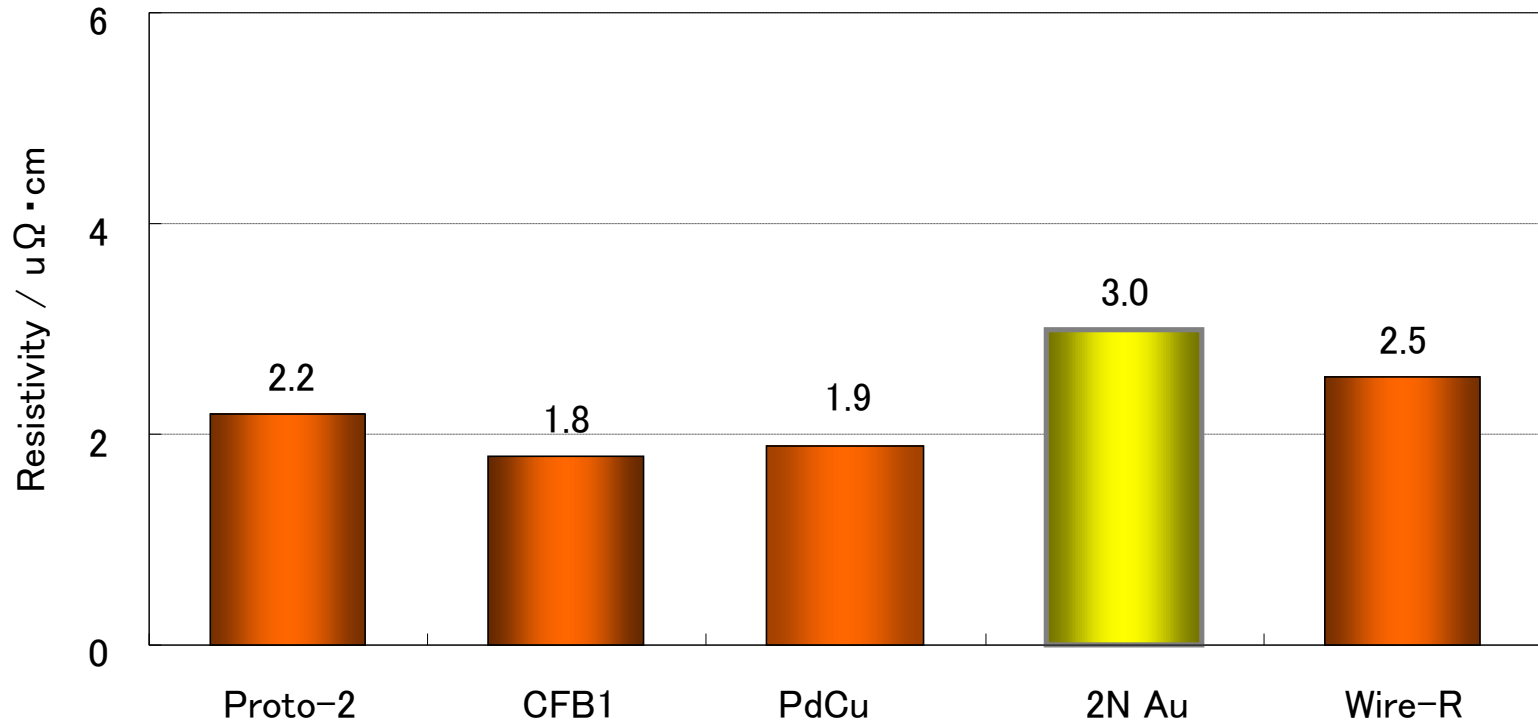
【Outline of Measurement】



Compression stress of FAB of Cu alloy is almost same as bare Cu.

Resistivity

Resistivity ($\mu\Omega \cdot \text{cm}$) AVE



Constant Current Regulator : TORISHA TYPE CCR 110-1

Digital Multimeter : Agilent 34401A

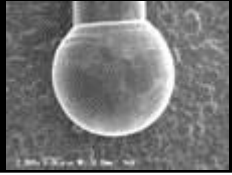
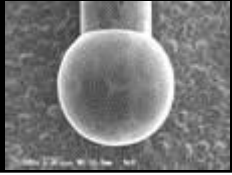
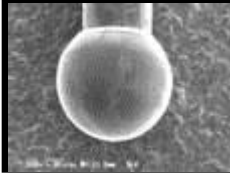



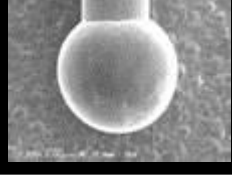
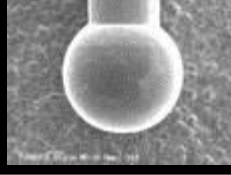

Tester : sanwa PC520 Number : n=3

Temperature : 25°C

Resistivity of Cu alloy is lower than 2N-Au and Wire-R.

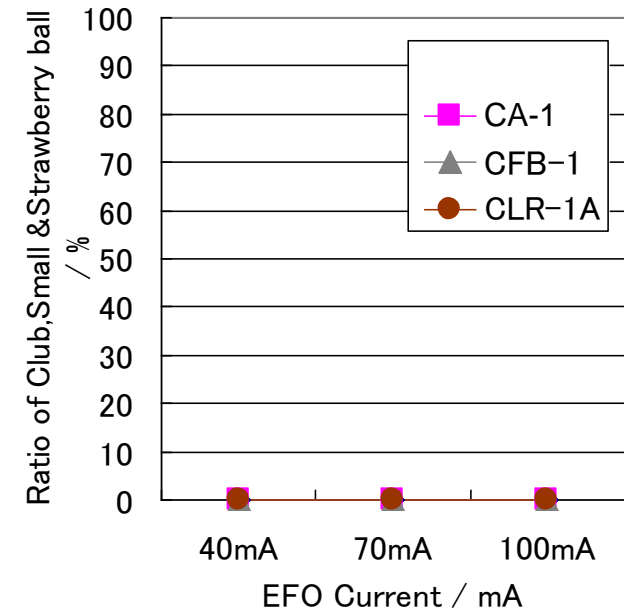
FAB formation

Observation of FAB

EFO Current [mA]	40	70	100
EFO Time [usec]	331	161	101
Cu alloy			
Bare Cu			
PdCu			

Cu alloy has same FAB formation window as bare Cu and PdCu .

Ratio of Club, Small & Strawberry Ball



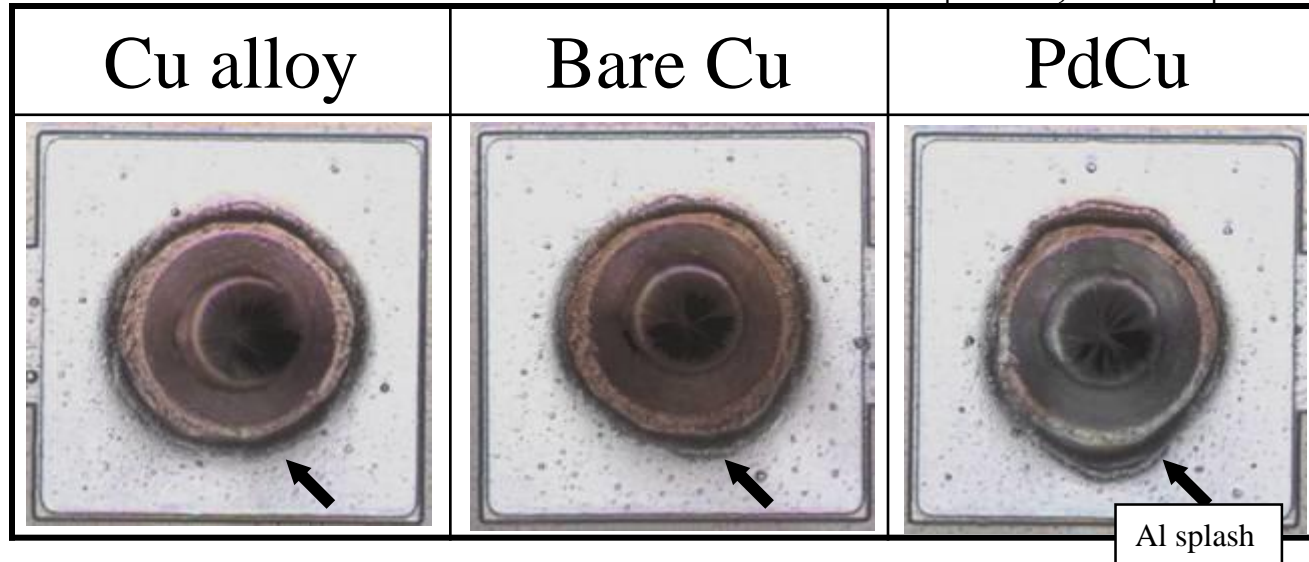
- Wire Information
 - Wire Dia :φ20um
 - FAB Size Target :35um
- Bonding Condition
 - Bonder : KnS Maxum plus (Cu Kit)
 - Capillary : SPT SU-25080-385F-ZU34TP
- Loop Parameters
 - FREE-AIR-BALLS
- Ball Parameter
 - Wire Dia:0.79mil
 - Tail extension:1.5mil
 - EFO GAP:40mil
 - Flow Gas: N2+5%H2 ,0.5L/min

- Bond 2 Parameters
 - Tip:5mils
 - C/V0.5mils/ms
 - USG Current:100mA
 - USG Bond Time:7ms
 - Force:35gf
- Evaluation Conditions
 - Observation of FAB
 - Device:KEYENCE VE-9800 (SEM)
 - Magnification :×2000
 - Ratio of Club ball etc..
 - Device:OLYMPUS Measuring Micro Scope STM6
 - Object Grass:×20
 - N=200

1st Bondability-1

Observation of Squashed Ball (1st bonding condition of All wires are same.)

Wire : $\phi 20\mu\text{m}$, FAB : $\phi 38\mu\text{m}$

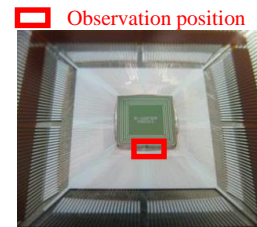


Al splash

- Bonding condition
 - Wire Dia : 20 μm
 - Bonder:KnS Maxum Plus (Cu kit)
 - Capillary :SPT SU-25080-385F-ZU34TP
 - Die: TANAKA TEG Al-0.5%Cu, $t=0.8\mu\text{m}$ (Renesas)
 - Sub:QFP-200(Ag electro plating)
 - Bonding Temp:220°C
 - FAB size (Target):38 μm
 - Squashed ball size (Target)
 - :X,Y=48 $\pm 2\mu\text{m}$,Z=11 $\pm 1\mu\text{m}$
 - Flow Gas : N2+5%H2, 05L/min
- Ball Parameter
 - Wire Diameters:0.79mill
 - FFO Fire Mode:Ball Size
 - Ball size:1.55(Proto-1,2,CFB-1),1.57(CLR1A)
 - EFO Current:70mA,EFO Gap:30mils
 - Tail extension:10mils

- Bond 1 Parameters
 - Tip:10mils ,C/V:0.3mils/ms, V Mode,USG
 - Mode:Contact Current, USG Current:60mA,
 - USG Bond Time:10ms, USG Pre-Bleed:55mA,
 - USG Profile:Square, Force:20gf, Initial force:30gf,
 - Initial Force Time:33%, Force Ramp Time:10%,
 - X-Scrub:3 μm , Y-Scrub:0 μm , Scrub Cycles:1,
 - Scrub Phase:90deg, 1st Scrub Mode:Pre-USG

The state of Al splash of Cu alloy is almost same as bare Cu.



Bond Layout

1st Bondability-2

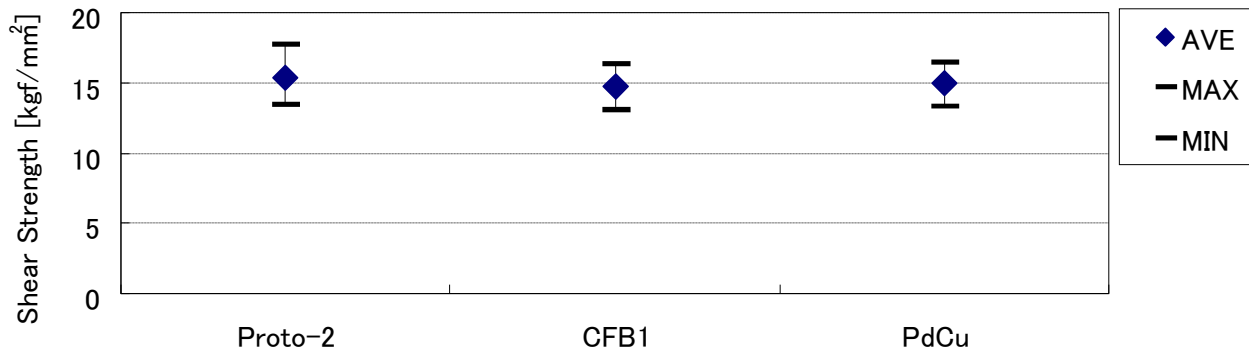
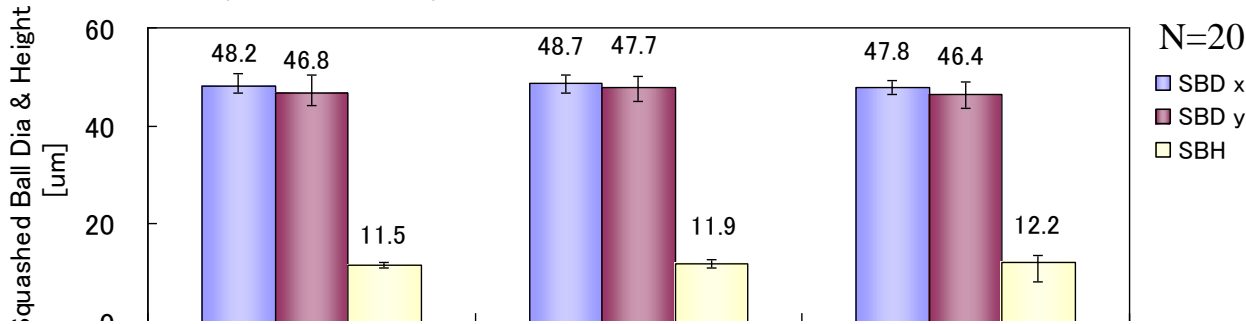
Squashed Ball size & Shear strength

(1st bonding condition of All wires are same.)

· Bonding condition
 Wire Dia : 20um
 Bonder:KnS Maxum Plus (Cu kit)
 Capillary :SPT SU-25080-385F-ZU34TP
 Die: TANAKA TEG Al-0.5%Cu, t=0.8um (Renesas)
 Sub:QFP-200(Ag electro plating)
 Bonding Temp:220°C
 FAB size (Target):38um
 Squashed ball size (Target)
 :X,Y=48±2um,Z=11±1um
 Flow Gas : N2+5%H2, 05L/min

· Ball Parameter
 Wire Diameters:0.79mill
 FFO Fire Mode:Ball Size
 Ball size:1.55(Proto-1,2,CFB-1),1.57(CLR1A)
 EFO Current:70mA,EFO Gap:30mils
 Tail extension:10mils

Wire:φ20um, FAB:φ38um

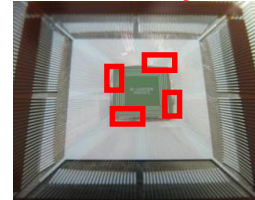


eters
 :0.3mils/ms,
 Code:Contact Current,
 5mA, USG Bond Time:10ms,
 :55mA, USG Profile:Square,
 ial force:30gf, Initial Force Time:33%,
 ne:10%, X-Scrub:3um, Y-Scrub:0um,
 Scrub Phase:90deg,
 :Pre-USG

lition
 size
 Measuring Micro Scope STM6
 100

· Shear strength
 Equipment: dage BT4000
 Shear Speed:125um/s
 Shear height:3um
 N = 20

Measurement position

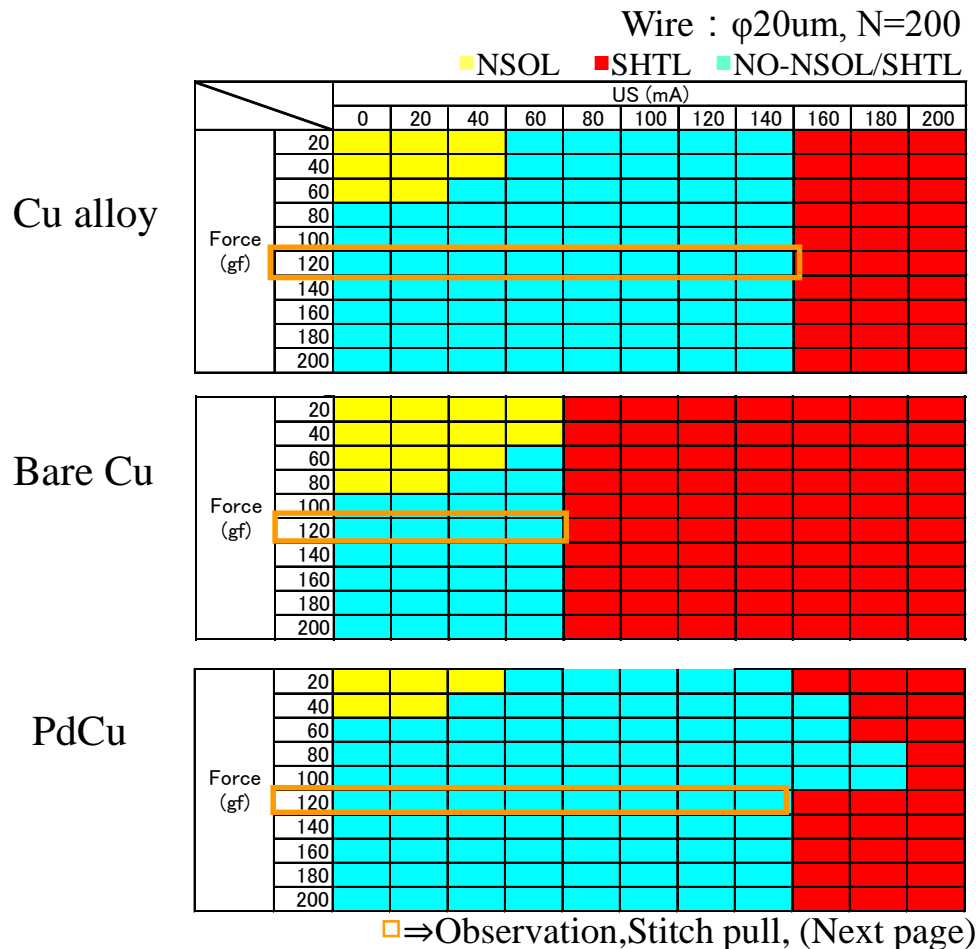


Bond Layout

Shear strength of Cu alloy is same as bare Cu and PdCu.

2nd Bondability-1

Bonding window (Ag electroplating / QFP Dummy)



Bond Layout

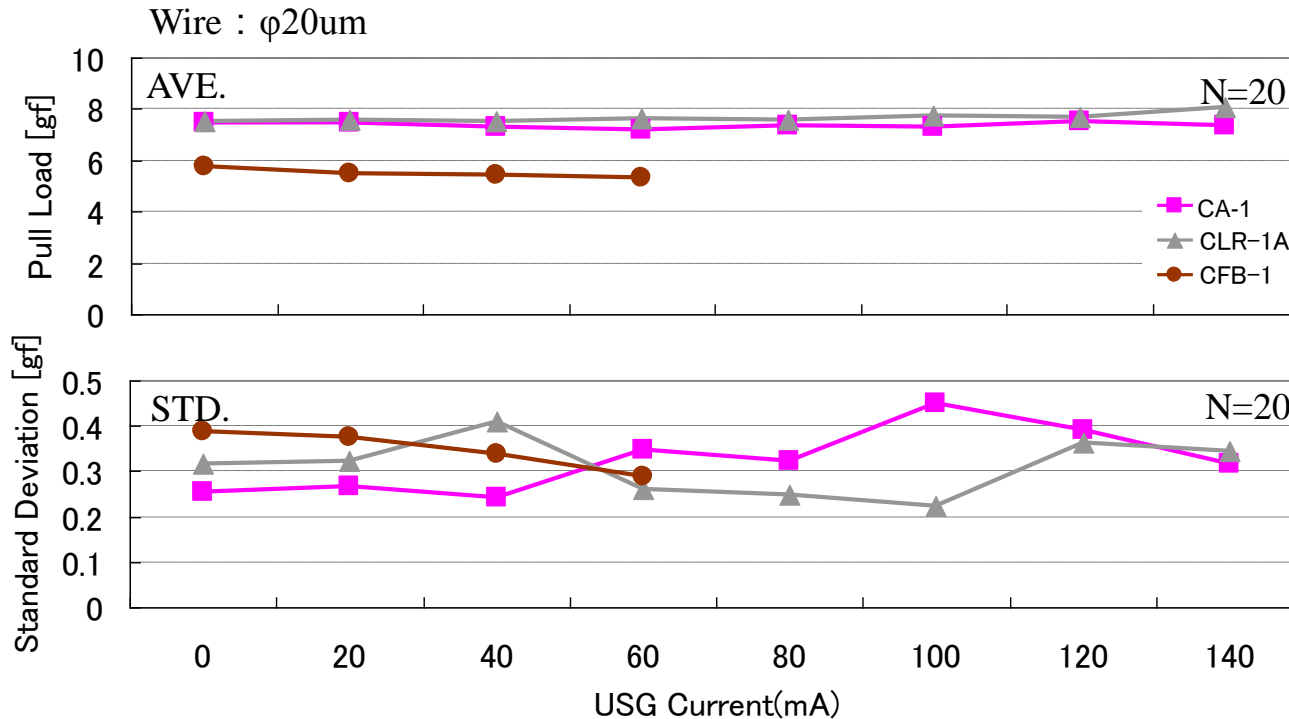
- Bonding condition
- Wire Dia : 20um
- Bonder: KnS Maxum Plus (Cu kit)
- Capillary : SPT SU-25080-385F-ZU34TP
- Sub: Dummy substrate ,Ag electro plating
- Bonding Temp: 220°C
- FAB size Target: 38um
- Flow Gas : N2+5%H2, 05L/min
- Bond 2 Parameters
- Tip: 10mils , C/V: 0.5mils/ms,
- Contact Threshold: 70%, USG Bond Time: 7ms
- Power Equ Factor: 100%, USG Pre-Bleed: 0mA,
- Init'l Force: 50g, Init'l Force Time: 33%
- Tail XY Scrub: 0um
- Z-Tear USG: 50mA, Z-Tear Speed: 10%
- Tail Scrub USG: 0mA,
- Evaluation condition
- Squashed Ball size
- OLYMPUS Measuring Micro Scope STM6
- Object Grass: ×20
- N=200

2nd Bonding window of Cu alloy is wider than bare Cu and PdCu.

2nd bondability-2

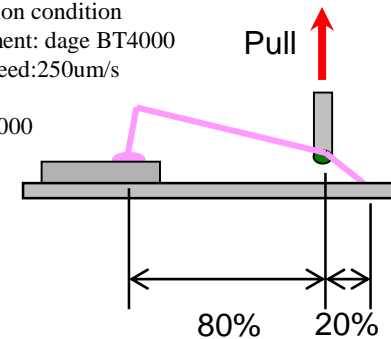
Stich Pull Test (Ag electroplating / QFP Dummy)

· Bonding condition
 Wire Dia : 20um
 Bonder: KnS Maxum Plus (Cu kit)
 Capillary : SPT SU-25080-385F-ZU34TP
 Sub: Dummy substrate ,Ag plating
 Bonding Temp: 220°C
 FAB size Target: 38um
 Flow Gas : N₂+5% H₂, 05L/min



Bond Layout

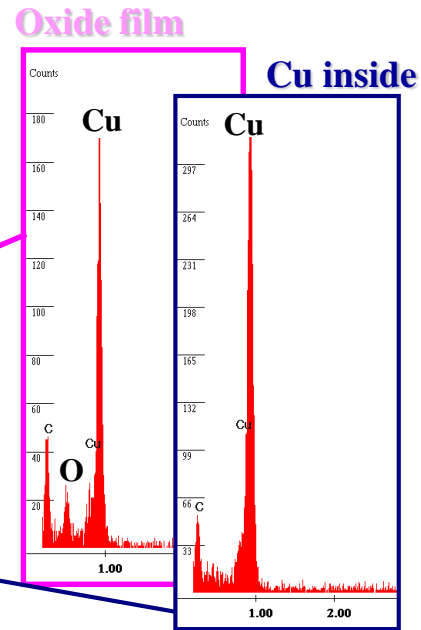
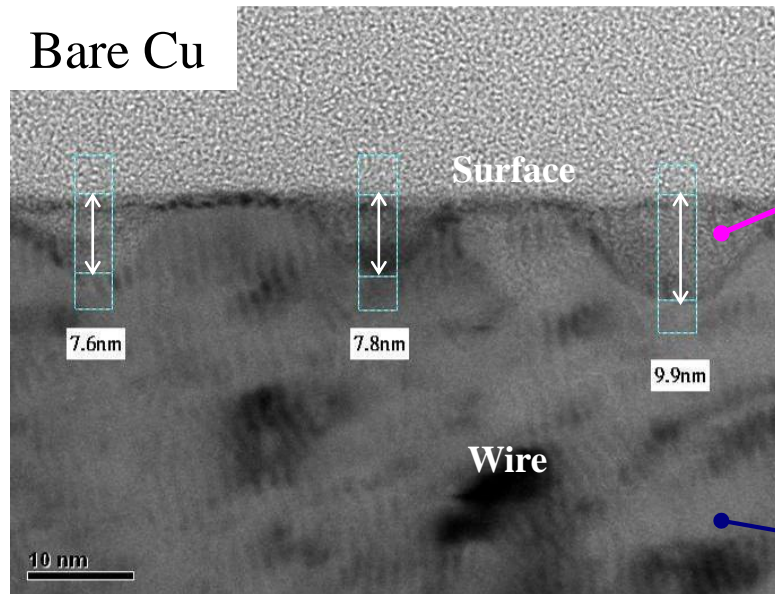
Evaluation condition
 Equipment: dage BT4000
 Pull Speed: 250um/s
 N = 20
 Dage: 4000



Stich Pull strength of Cu alloy is higher than bare Cu.
 (Almost same as PdCu)

Comparison of Oxide film on wire surface

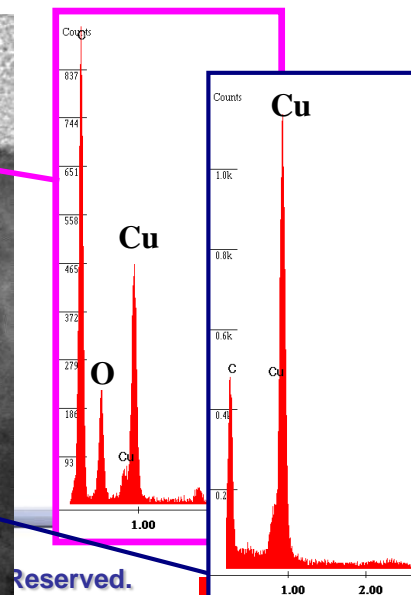
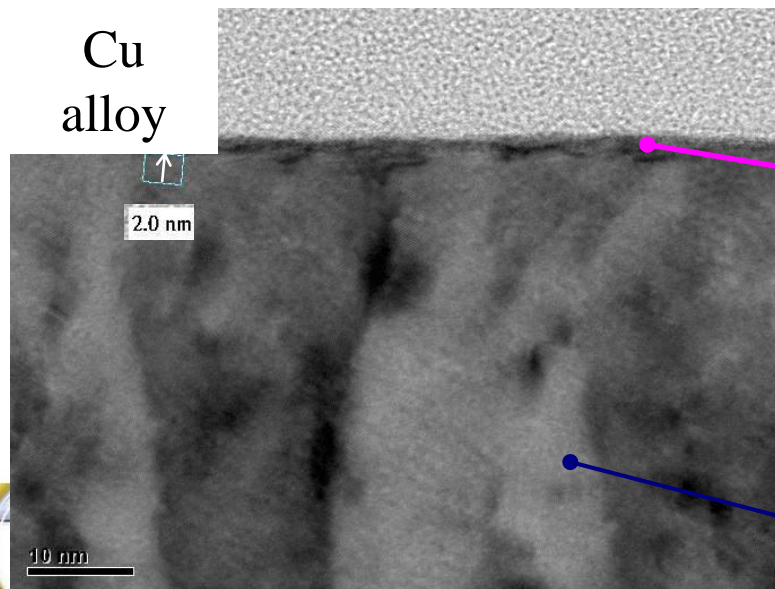
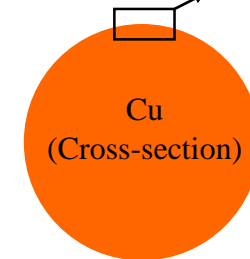
【Cross-sectional View by TEM/EDX】



Evaluation wire : Cu alloy, Bare Cu
Wire Dia : 18mm (Cross-section)
Equipment : TEM/EDX
Magnification : ×220k

*
*The sample for observation was adjusted by FIB (Micro sampling).

Micro sampling by FIB



Cu alloy has a uniform oxide film thinner than Bare Cu. Alloy material can prevent oxidization.

Disclaimer:

Accuracy of TEM/EDX may be affected by unevenness of the surface.

Oxide film area is estimated from multiple analyses

Reliability test Overview

◆ Test Condition (HTS and HAST)

Evaluation wire: Cu alloy, 4N-Cu

Diameter: 20um

Squashed ball size: X,Y=50um,Z=10um (Up to 13kg/mm²)

Gas Flow: N₂+5%H₂(0.5L/min)

Flame : QFP200pin (Measurement number : 88pairs), 42 alloy, Ag-plated

Substrate: FR-4 32pin, (Measurement number : 64pairs), Au electro-plating

Chip: TANAKA TEG Chip Al-0.5%Cu, t=0.8um (Renesas)

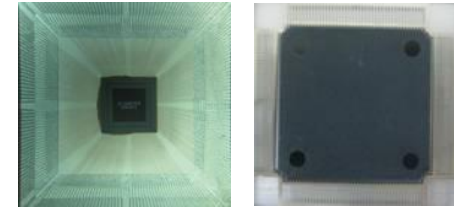
Bonder: K&S Maxum Plus (Cu kit)

Capillary : SPT SU-25080-385F-ZU34TP

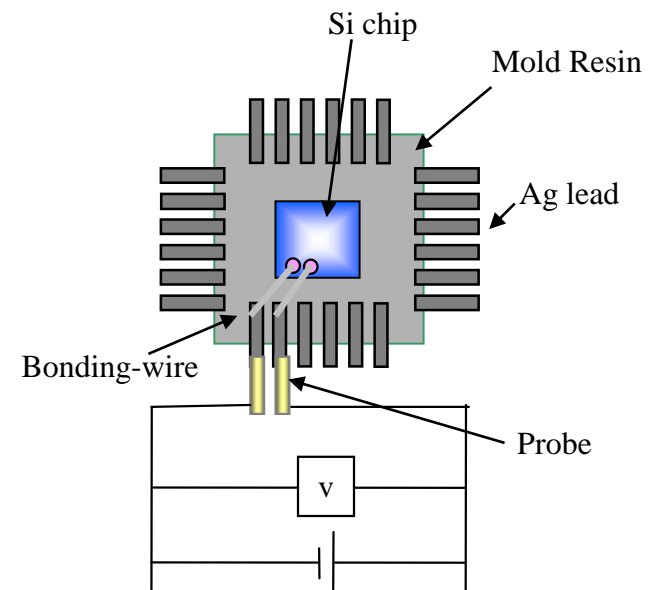
Mold resin: Nitto Denko MP-8000CH, GE7470L-A

Mold temperature: 180 deg C

Cure: 175 deg C, 5hrs in the air



Mold Temp.=180°C
Post Cure=175°C×5hr



【Test condition】

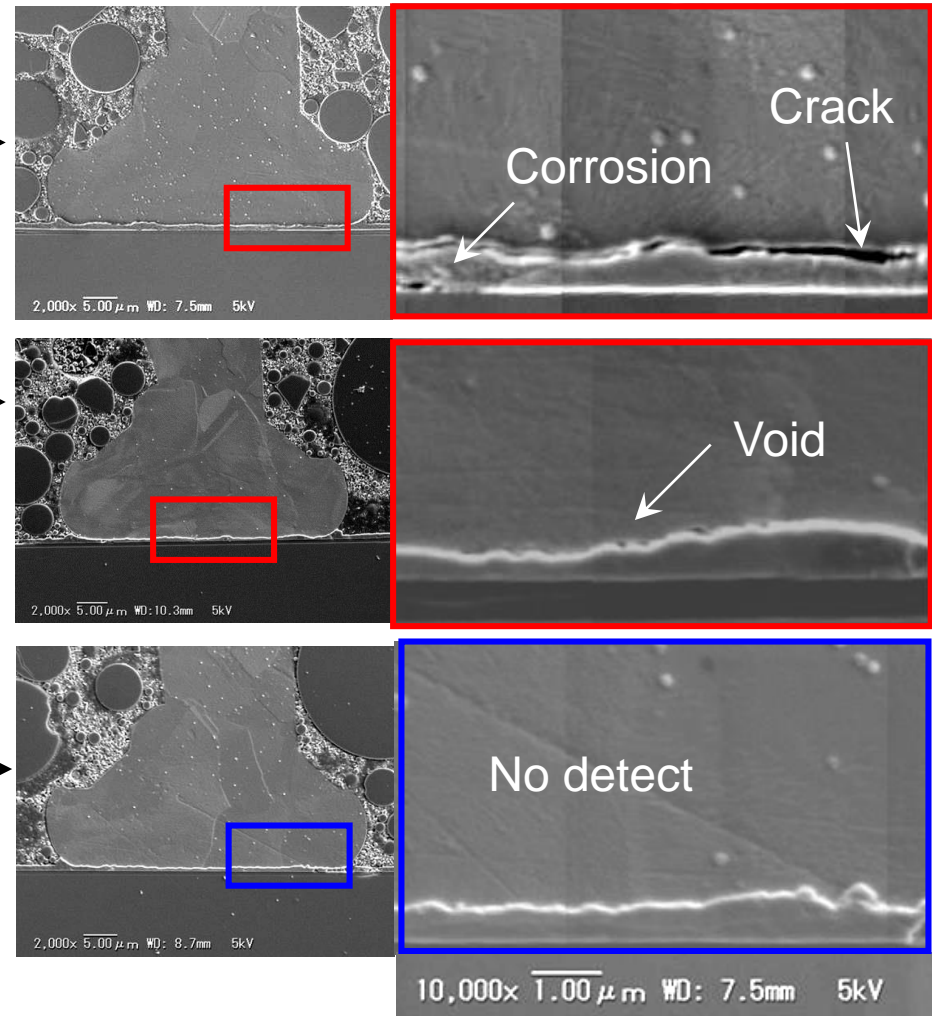
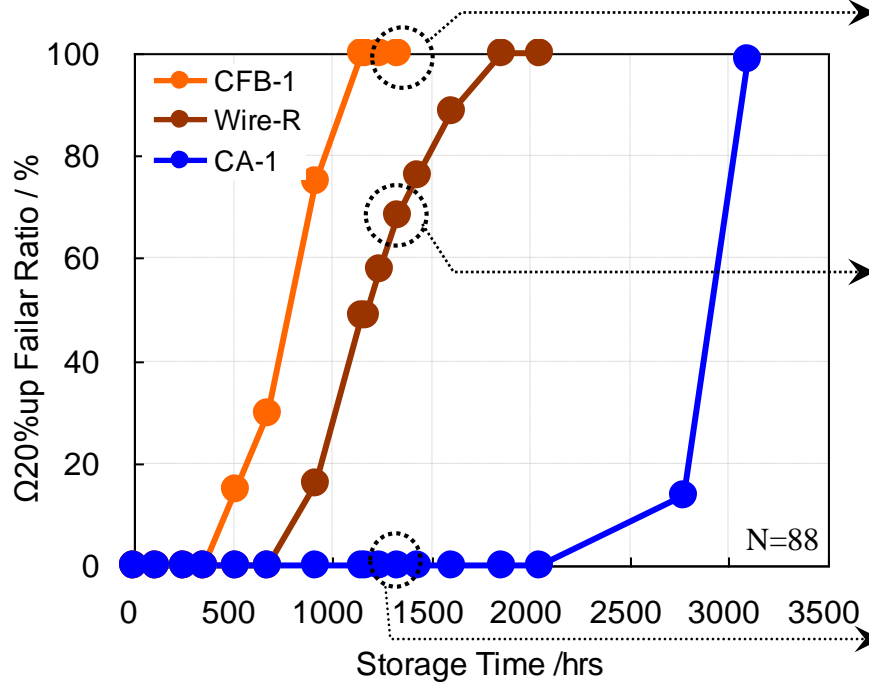
1. HTS: 175°C, QFP, Non-Green resin(MP-8000CH)
2. uHAST: 130deg C 85%rh, BGA, Green resin (GE7470L-A)

*no preconditioning, no reflow

Reliability

HTS 175°C, QFP, Non-Green resin

◆ Failure Ratio (Ω20%up) & Failure Analysis

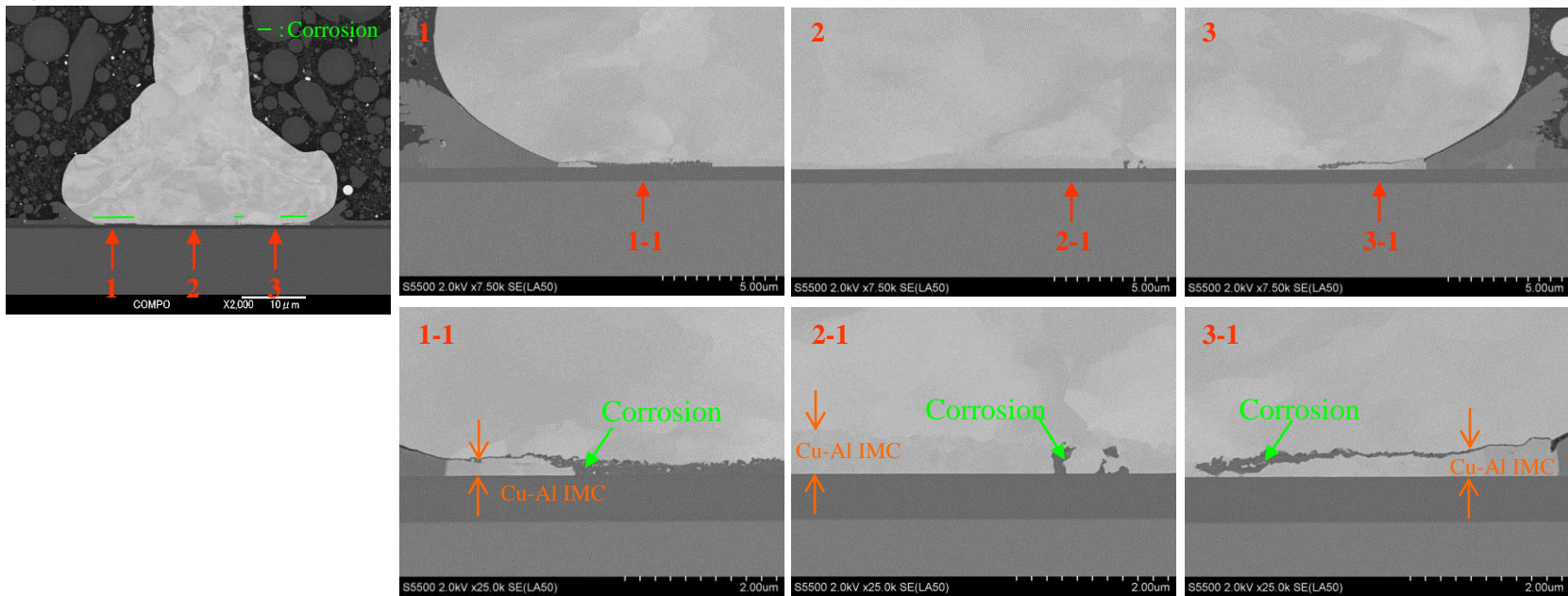


Cu alloy shows no failure until 2000 hrs.

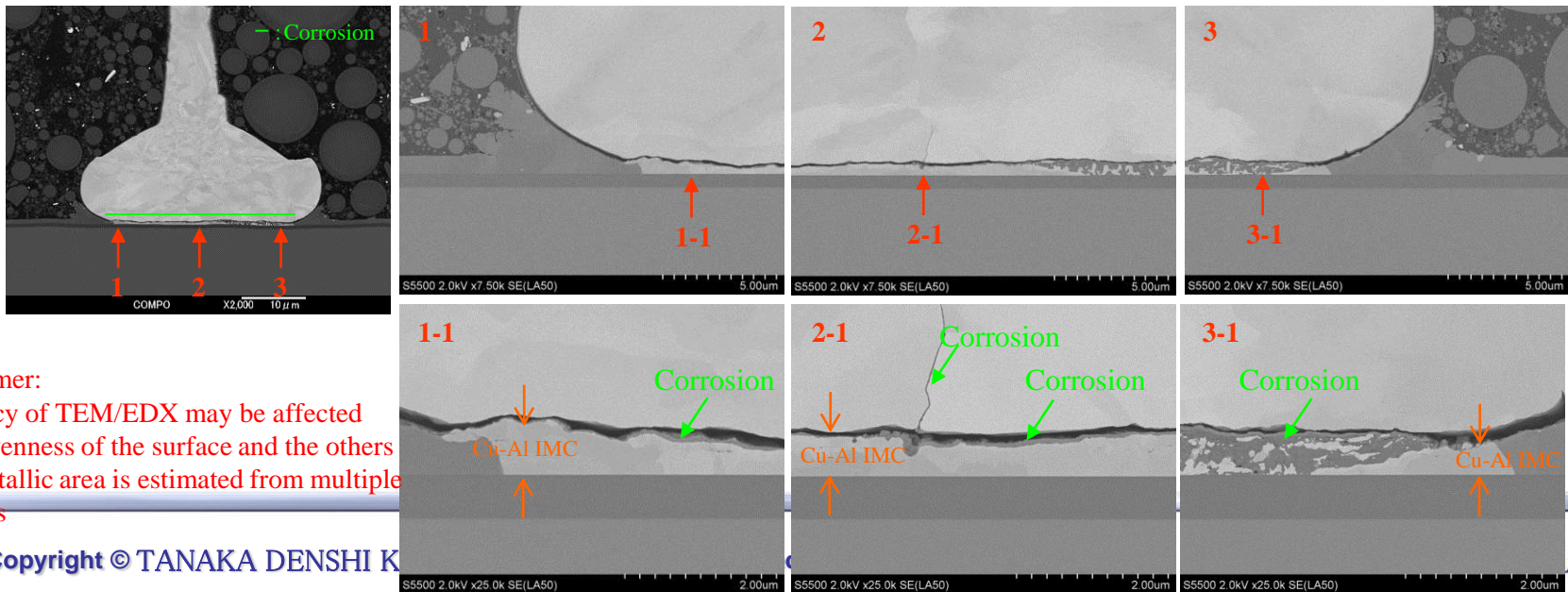
Cu alloy has no detect at cross-section of 1st Ball/Pad at 1300hrs.

Comparison of Cu-Al inter-metallic @HTS 175°C 1300hrs

Cu alloy



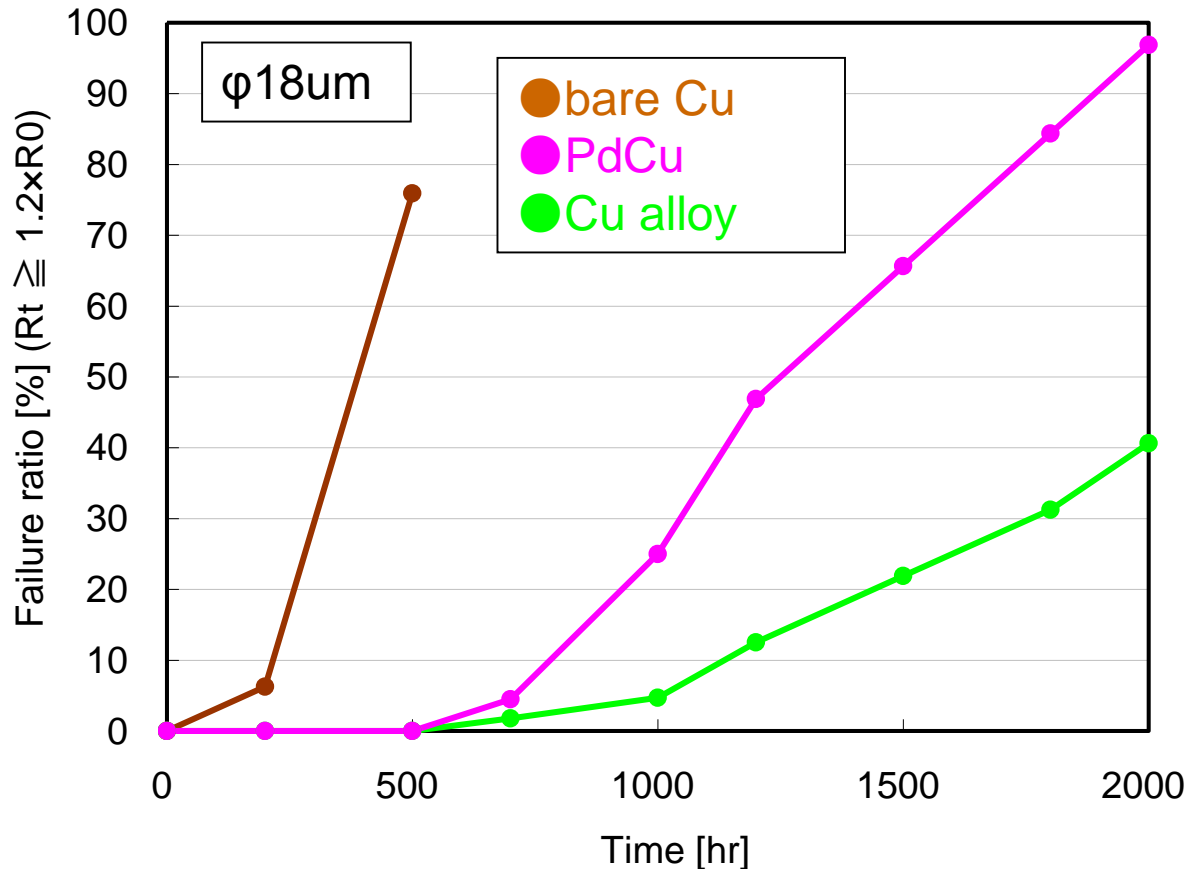
Bare Cu



Disclaimer:
Accuracy of TEM/EDX may be affected by unevenness of the surface and the others
Intermetallic area is estimated from multiple analyses

Reliability

HTSL - 200°C , BGA , Green resin



<Bonding conditions>

Bonder: ProCu

Gas flow rate:

Forming, 0.50l/min(EFO)

EFO Current: 65mA

Wire dia.: 18um

Squashed ball dia. : 36um

Squashed ball thickness : 9um

Shear stress: over 12kgf/mm²

SPT SU-23060-283F-ZU34TP

<other conditions>

Die :WALTS MB6020-0102JY,

Pad: Al-0.5%Cu, 0.8umt

substrate:OKI PBGA32pin (HF)

256point, 128circuit

(=16circuit/IC × 4IC × 2Frame)

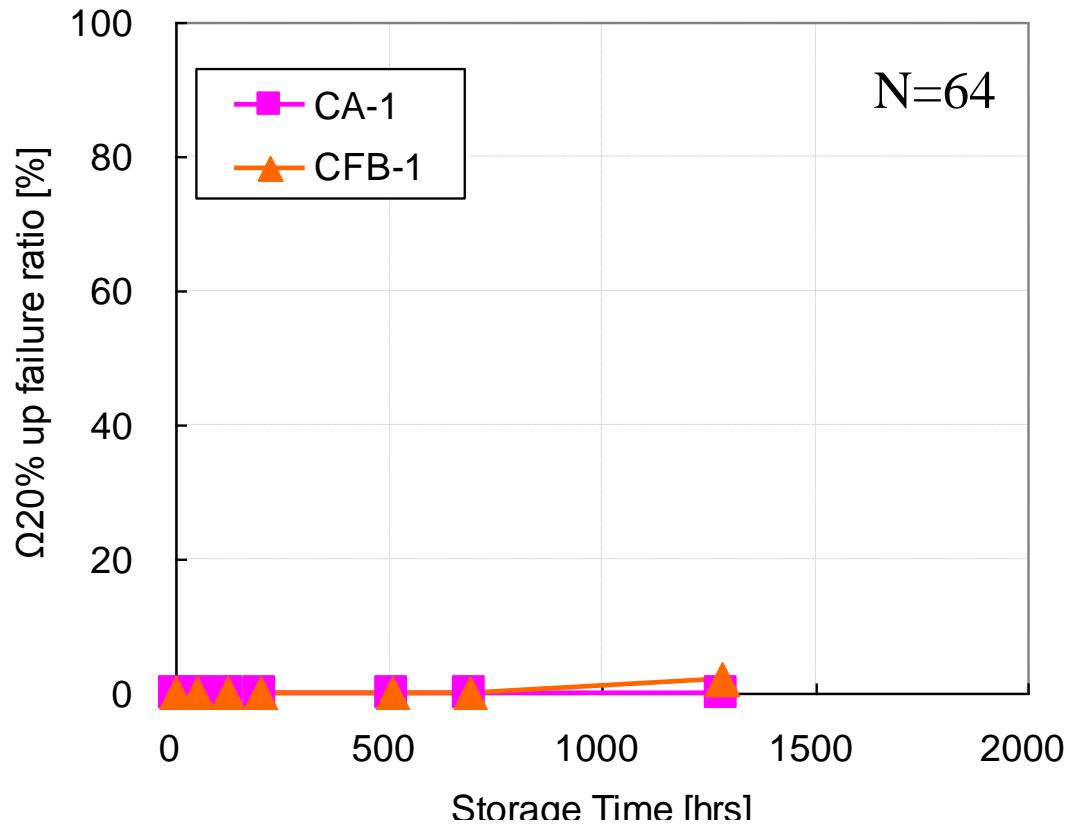
Initial resistance:0.8-1.0Ω

Cu alloy is better than BareCu / PCC about HTSL test.

Reliability

uHAST 130deg C 85%rh, BGA, Green resin

◆ Failure Ratio ($\Omega 20\% \text{up}$)



Cu alloy shows no resistance changes until 1200 hrs.

Summary (Details of Technical Data)

- Cu alloy has a larger breaking load and elongation compared with bare Cu and PdCu wire.
- Cu alloy has a lower resistivity compared with 2N-Au.
- Cu alloy has same FAB formation window as bare Cu and PdCu.
- Cu alloy has same compression stress on FAB compared with bare Cu.
- Cu alloy has wider 2nd window than bare Cu.
- Cu alloy has superior reliability (HTS) performance than bare Cu.

End of Report

Summary of Cu alloy wire evaluation

Category		Pd coated Cu	Cu alloy	bare Cu
type		CLR-1A	CA-1	CFB-1
Resistivity		★★★	★★	★★★
Reliability	HTS	★★	★★~★★★★	★
	HAST	★★★	★★~★★★★	★
FAB formation		★★	★★	★★
1st bondability		★	★★	★★
2nd bondability		★★★	★★	★
Price		★	★★	★★★

Cu alloy wire has no major negative point.

Thank you !
THANK YOU !

TANAKA DENSHI KOGYO K.K.

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